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APPLICATION NO.	FIL	ING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	ATTORNEY DOCKET NO. CONFIRMATION NO.	
09/334,646	06	5/17/1999	SHUNPEI YAMAZAKI	0756-1984 5565		
31780	7590	08/20/2003				
ERIC ROBI	NSON		EXAMINER			
PMB 955 21010 SOUTI		. = -		HU, SHOUXIANG		
POTOMAC F	ALLS, V	A 20103		ART UNIT	PAPER NUMBER	
				2811		
				DATE MAILED: 08/20/2003	DATE MAILED: 08/20/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

			Un
	Application No.	Applicant(s)	
	09/334,646	YAMAZAKI ET AL	
Office Action Summary	Examiner	Art Unit	
	Shouxiang Hu	2811	
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet	with the correspondence ad	dress
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). Status	36(a). In no event, however, may within the statutory minimum of will apply and will expire SIX (6) No cause the application to become	y a reply be timely filed thirty (30) days will be considered timely MONTHS from the mailing date of this or a ABANDONED (35 U.S.C. § 133).	
1) Responsive to communication(s) filed on 13 J	<u>une 2003</u> .		
2a)⊠ This action is FINAL . 2b)□ Thi	s action is non-final.		
3) Since this application is in condition for allowa closed in accordance with the practice under			e merits is
Disposition of Claims	as in the application		
4) Claim(s) <u>See Continuation Sheet</u> is/are pendir	•		
4a) Of the above claim(s) is/are withdrav 5) Claim(s) is/are allowed.	vii ironi consideration.		
5)	58_60 65 71_73 75_81	and 100-121 is/are rejected	
7) ☐ Claim(s) is/are objected to.	<u> </u>	<u>and 100-121</u> 19/are rejected.	•
8) Claim(s) are subject to restriction and/or	r election requirement		
Application Papers	ciconon requirement.		
9) The specification is objected to by the Examine	r.		
10) The drawing(s) filed on is/are: a) accep	ted or b) objected to b	y the Examiner.	
Applicant may not request that any objection to the	e drawing(s) be held in ab	eyance. See 37 CFR 1.85(a).	
11)☐ The proposed drawing correction filed on	is: a)∏ approved b)[disapproved by the Examin	er.
If approved, corrected drawings are required in rep	ly to this Office action.		
12) ☐ The oath or declaration is objected to by the Ex	aminer.		
Priority under 35 U.S.C. §§ 119 and 120			
13) Acknowledgment is made of a claim for foreign	priority under 35 U.S.	C. § 119(a)-(d) or (f).	
a)⊠ All b)⊡ Some * c)⊡ None of:			
1. Certified copies of the priority documents	s have been received.		
2. Certified copies of the priority documents	s have been received in	n Application No. <u>08/513,09</u> 0	<u>0</u> .
 3. Copies of the certified copies of the prior application from the International But * See the attached detailed Office action for a list 	reau (PCT Rule 17.2(a))) .	Stage
14) Acknowledgment is made of a claim for domestic	c priority under 35 U.S.	C. § 119(e) (to a provisional	l application).
 a) ☐ The translation of the foreign language pro 15)☐ Acknowledgment is made of a claim for domesti 	* *		
Attachment(s)			
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 35	5) Notice	ew Summary (PTO-413) Paper No of Informal Patent Application (PT	
S. Patent and Trademark Office			

Continuation of Disposition of Claims: Claims pending in the application are 1-3,8,11-14,16-19,32-34,38-43,52,53,58-60,65,71-73,75-81 and 100-121.

DETAILED ACTION

Priority

1. This application is a divisional of U.S. Application No. 08/938,310, filed on September 26, 1997, now U.S. Patent 5,959,313, which itself is a divisional of U.S. Application No. 08/513,090, filed on August 9, 1995, now U.S. Patent 5,731,613.

Pending and Active claims

2. Claims 1-3, 8, 11-14, 16-19, 32-34, 38-43, 52, 53, 58-60, 65, 71-73, 75-81 and 100-121 are currently pending and active.

Information Disclosure Statement

3. The information disclosure statement filed on June 17, 1999 fails to fully comply with 37 CFR 1.98(a)(2), which requires a legible copy of each U.S. and foreign patent; each publication or that portion which caused it to be listed; and all other information or that portion which caused it to be listed. No copies were found in this application and/or in its parent case (08/513,090) for the two references: Hayzelden et al., In Situ Transmission Electron Microscopy Study of Silicide-Mediated Crystallization of Amorphous Silicon; and, Kakkad et al., Low temperature Selective Crystallization of Amorphous Silicon. It has been placed in the application file, but the information referred to in those two references has not been considered.

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Claim Objections

4. Claims 104-121 are objected to because of the following informalities and/or defects:

Claims 104 and 113 each recite the term of "each respective second thin film transistor", but fail to clarify what is the relationship between it and the term of "a plurality of second thin film transistors" also recited in each of the two claim.

Accordingly, it should read as --each respective one of said plurality of second thin film transistors--.

Similarly, in claims 107 and 116, the term of "each respective second thin film transistor" should read as --each respective one of said some of the plurality of second thin film transistors--.

And, In claims 110 and 119, the term of "each respective second thin film transistor" should read as –said at least one of the plurality of second thin film transistors--.

Appropriate correction is required.

Claim Rejections - 35 USC § 103

5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

6. Claims 1-3, 8, 11-14, 16-19, 32-34, 38-43, 52, 53, 58-60, 65, 71-73, 75-81 and 100-103 are rejected under 35 U.S.C. 103(a) as being unpatentable over Zhang et al. ("Zhang"; US 5,403,772) in view of Kuribayashi et al. ("Kuribayashi"; US 5,233,447) and/or Matsueda (US 5,173,792).

Zhang discloses an active matrix type LC display device (Figs. 1-8A, particularly, Fig. 8A), comprising: a pixel matrix portion (104) having a plurality of pixels on an insulating substrate (107); and a peripheral driver circuit portion (101 and 102) on the same insulation substrate, thin film transistors (TFTs) in the driver circuit portion each having a channel forming region in one of the separate semiconductor layers (11a and 11b) provided on an insulating surface, wherein the channel forming region is provided in a region which can be regarded as effectively monocrystalline silicon (see col. 6, lines 13-15); and, the channel forming region contains impurities (a type of point defects) of carbon, nitrogen and oxygen at a concentration less than 10¹⁸ cm⁻³, which meets the limitation of each channel forming region "containing carbon and nitrogen at a concentration of 5x10¹⁸ cm⁻³ or less, respectively, and containing oxygen at a concentration of 5x10¹⁹ cm⁻³ or less, recited in the claimed invention.

It is noted that, since the channel forming region in Zhang is formed with a method which is substantially the same as the one used in the claimed invention, the method used in Zhang is regarded as being inherently capable of forming the channel forming region having no linear defects or surface defects. In addition, one of ordinary skill in the art would readily recognize that it is always desirable to form the channel

forming region having no linear defects or surface defects for achieving good channel performance.

Although Zhang does not expressly disclose that the display device further comprises a buffer circuit in the driver circuit, one of ordinary skill in the art would readily recognize that such a buffer circuit is normally required for achieving desired driving output, as evidenced in Kuribayashi (see the buffer circuit (81) in Fig. 8; also see col. 8, lines 56-66). It is also evidenced in Kuribayashi (see Fig. 19) that an active matrix type display device commonly further comprises a memory, a decode and a display system for maintaining its basic display functionality.

Zhang does not expressly disclose that the peripheral driver circuit portion comprises at least two TFTs connected in parallel. Matsueda discloses an active matrix type LC display device (Figs. 1-12, particularly, Fig. 7), comprising: at least two TFTs (100A and 100B) provided on the surface of an insulating layer (110); a common gate wire (102); a common source wire (Xm); a common drain wire (101), wherein the channel forming regions of the parallel-connected transistors are provided in separate semiconductor layers respectively. Matsueda teaches that the reliability of a basic control element comprising two or more parallel-connected TFTs is better than that of a basic control element comprising a single TFT.

It would therefore have been obvious to one of ordinary skill in the art at the time the invention was made to incorporate the parallel-connected TFTs of Matsueda into the driver circuit in the display device of Zhang with the driver circuit including a buffer circuit, per the teaching of Kuribayashi, so that a display device having both pixel and

driver portions formed on a same insulating substrate with good reliability in both of them would be obtained.

Regarding claims 11-14, 16-19 and 32-34, as mentioned above, an active matrix type display device commonly further comprises a memory, a decode and a display system for maintaining its basic display functionality.

Regarding claims 38-43, 52, 53, 58-60 and 65, it is noted that it is well known in the art that the carrier mobility and crystallization quality are strongly correlated with the Raman spectrum width ratio and intensity ratio, as evidenced in the prior art such as in Fig. 3 of Yamazaki et a. (5,608,232), which shows that the Raman spectrum width ratio of W/W₀ is 2.0 or less; and, that the Raman spectrum intensity ratio of I/I₀ is about 0.8 or more.

It would therefore have been obvious to one of ordinary skill in the art at the time the invention was made to make the device collectively taught by Zhang, Kuribayashi and Matsueda with the Raman spectrum width ratio of W/W₀ being 2.0 or less and the Raman spectrum intensity ratio of I/I₀ being about 0.8 or more, so that improved display device performance with high-mobility TFTs would be achieved.

7. Claims 104-121 are rejected under 35 U.S.C. 103(a) as being unpatentable over Zhang et al. ("Zhang"; US 5,403,772) in view of Matsueda (US 5,173,792).

Zhang discloses an active matrix type LC display device (Figs. 1-8A, particularly, Fig. 8A), comprising: a pixel portion (104) having plurality of first thin film transistors (TFTs) connected respectively to a plurality of pixel electrodes formed on (or over) an

insulating substrate (107; see Fig. 8(A)); and a plurality of second TFTs forming a driver circuit (101 and/or 102) for driving the pixel portion, wherein each of the second TFTs has a channel area in a semiconductor layer (11a or 11b) crystallized from an amorphous silicon layer (see col. 6, lines 13-15)

Zhang does not expressly disclose that each (or some, or at least one) of the second TFTs comprising a plurality of channel areas connected in parallel.

However, Matsueda discloses an active matrix type LC display device (Figs. 1-12, particularly, Fig. 7), comprising a TFT with a plurality of channel areas (in 100A and 100B, separated in the channel width direction) electrically connected in parallel.

Matsueda teaches that the reliability of a basic control element comprising a plurality of parallel-connected channel areas is better than that of a basic control element comprising a single channel area.

It would therefore have been obvious to one of ordinary skill in the art at the time the invention was made to incorporate the parallel-connected channel areas of Matsueda into both of the first and second TFTs of Zhang, so that a display device having both pixel and driver portions formed on a same insulating substrate with good reliability in both of them would be obtained. In addition, the limitation of "subject to laser annealing respectively" as recited in the claims is a process limitation. And, it would not carry patentable weight in the claims drawing to a structure, because distinct structure is not necessarily produced. In re Thorpe, 227 USPQ 964, 966 (Fed. Cir. 1985).

Response to Arguments

8. Applicant's arguments filed on June 13, 2003 have been fully considered but they are not persuasive.

In response to applicant's argument that there is no suggestion to combine the references as Matsueda only teaches to have parallel-connected TFTs in the pixel portion and it is intended to solve a specific problem not related to the buffer circuit of the claimed invention, the examiner recognizes that obviousness can only be established by combining or modifying the teachings of the prior art to produce the claimed invention where there is some teaching, suggestion, or motivation to do so found either in the references themselves or in the knowledge generally available to one of ordinary skill in the art. See In re Fine, 837 F.2d 1071, 5 USPQ2d 1596 (Fed. Cir. 1988) and In re Jones, 958 F.2d 347, 21 USPQ2d 1941 (Fed. Cir. 1992). In this case, Kuribayashi teaches that an active matrix type display device commonly comprises a buffer circuit, a memory, a decode and a display system for maintaining its basic display functionality. And, Matsueda teaches that the reliability of a basic control element comprising two or more parallel-connected TFTs is better than that of a basic control element comprising a single TFT. In addition, Zhang further teaches that that the TFTs of the driver portion and the TFTs of the pixel portion are both formed on a same insulating substrate. With these teachings, one of ordinary skill in the art would readily recognize that the reliability of the TFTs in both of the pixel portion and the driver portion should be concerned if the reliability of the TFTs in any of the pixel portion and the drive portion is concerned since all the TFTs are formed on a same substrate and function as

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a basic control element. Therefore, one of ordinary skill in the art would readily recognize that the reliability of the display device of Zhang would be improved if the TFTs in both of the pixel portion and the driver portion including the buffer circuit are formed of two of more parallel-connected TFTs.

Conclusion

9. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shouxiang Hu whose telephone number is (703) 306-5729. The examiner can normally be reached on Monday through Thursday, 7:30 AM to 6:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Thomas can be reached on (703) 308-2772. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9318 for regular communications and (703) 872-9319 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

SH August 15, 2003

SHOUXIANG HU

Shorwacogflee